

# Fast intraband capture and relaxation of electrons in InAs/GaAs self-assembled quantum dots

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#### Summary

- One and two colour pump-probe study of intraband relaxation processes in n-type InAs/GaAs quantum dots (QDs) for electron transition energies between 100 and 180 meV.
- Relaxation time from high energy QD excited / wetting layer states ~5ps in the presence of holes and ~8ps in the absence of holes.

# Intraband pump-probe results

~120 meV

0 meV

continuum ~230 meV GaAs barrier WL-states ~170 meV

*d*-states

s-state

Probe p-states  $\rightarrow$  ~55 meV

InAs QD

Pump

smissio

ed



### • 45° multipass waveguide geometry (~10 passes through the QD layers)

- Using intraband absorption spectroscopy information about the electron energy structure in QDs can be obtained
- One colour pump-probe measurements
- Only electrons are excited (no holes)

Wavelength (µm)



- Increase of the QD population decreases the capture/relaxation time.
- Fast electron relaxation in QDs occurs multiphonon emission due to via nonadiabatic electron-phonon interaction directly into the QD ground state
- sequential scattering process  $\Rightarrow$ involving the p-state can be ruled out (because s-p transition  $\tau$ ~50ps).
- Due to the relatively long high energy excited state lifetime (~10ps), QD photodetectors infrared the have for higher efficiencies than potential quantum well infrared photodetectors.





- •Relaxation time for electron energy of ~140meV is ~4 ps, interesting because p-s relaxation time is  $\sim$ 50ps in the same sample [1]  $\Rightarrow$  apparently electrons avoid p-state
- •Clear bi-exponential dependence is observed at 180 meV with short decay time of ~8 ps and long decay time of ~300 ps at 10K
- Increase of the QD population from ~1 to ~6 e/dot decreases the capture/relaxation time from ~4.8 ps to ~2 ps at 8 µm
- The long decay time decreases from ~400 ps to ~13 **ps** with increase of number of electrons in QDs from ~1 to ~6

**Temperature dependence** Interband pump – intraband probe results —— PLE signal at 1120 nm, 77 K ~10 μm (~125 meV) - fit: p=4, E<sub>phonon</sub>=25 meV, S=1 *Ih* & *hh* WL states Interband pump intraband probe ~8 µm (~155 meV) --- fit: p=5, E<sub>phonon</sub>=25 meV, S=1.2 





- Fast relaxation time and weak temperature dependence nonadiabatic electron-phonon interaction (observed previously in PbSe colloidal QDs [2]).
  - From [3], for (p+4)<sup>2</sup>>>4S<sup>2</sup>n(n+1) where: p – number of emitted phonons, S – Huang-Rhys factor

# $\Gamma = \Gamma_0 \cdot (1+n)^p \cdot e^{-2 \cdot S \cdot n}$ n = - $\hbar\omega$ $e^{kT} - 1$

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#### References

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